EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	479	((workpiece or semiconductor or substrate or wafer) near5 (wash or washed or washer or washing or clean or cleaner or cleaning or cleaned or decontaminat$4) near5 (foam$4 or froth$4 or bubbles or sud$4))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/14 04:44
L2	8	((workpiece or semiconductor or substrate or wafer) near5 (wash or washed or washer or washing or clean or cleaner or cleaning or cleaned or decontaminat$4) near5 (foam$4 or froth$4 or bubbles or sud$4)) and ((foam$4 or froth$4 or bubbles or sud$4) near6 ozon$4)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2007/05/14 04:49